Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	SOI and (silicon adj on adj insulator)and cavity and portion and atoms and implant\$ and etch\$ and surface	USPAT	OR	ON	2005/04/23 12:38
L2	1121	material and cavity and portion and atoms and implant\$ and etch\$ and surface	USPAT	OR	ON	2005/04/23 12:39
L3	134	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI	USPAT	OR	ON	2005/04/23 12:39
L4	107	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI and selectively	USPAT	OR	ON	2005/04/23 12:39
L5	. 0	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI and (selectively adj implanting adj atoms)	USPAT	OR	ON	2005/04/23 12:40
L6	23	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI and selectively and hydrogen and helium	USPAT	OR	ON	2005/04/23 12:43
L7	. 0	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI and selectively and hydrogen and helium and (sub adj surface)	USPAT	OR	ON	2005/04/23 12:42
L8	0	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI and selectively and hydrogen and helium and (sub-surface)	USPAT	OR ·	ON	2005/04/23 12:42
L9	23	6 and (cylindrial or cavity or polygonal or concave or convex or sub or surface or removal or etch or etching or insulating or entire or atom or atoms or implantation or implanting or zone or wet or dry or silico o oxide or nitride or diamond or hafnium or lanthanum or aluminum or zirconium or saphire)	USPAT	OR	ON	2005/04/23 13:46
L10	1	("6534382").PN.	USPAT	OR	OFF	2005/04/23 13:46
L11	1	("6275296").PN.	USPAT	OR	OFF	2005/04/23 13:46

						
L12	1.	10 and (cylindrial or cavity or polygonal or concave or convex or sub or surface or removal or etch or etching or insulating or entire or atom or atoms or implantation or implanting or zone or wet or dry or silico o oxide or nitride or diamond or hafnium or lanthanum or aluminum or zirconium or saphire)	USPAT	OR.	ON	2005/04/23 13:49
L13	1	11 and (cylindrial or cavity or polygonal or concave or convex or sub or surface or removal or etch or etching or insulating or entire or atom or atoms or implantation or implanting or zone or wet or dry or silico or oxide or nitride or diamond or hafnium or lanthanum or aluminum or zirconium or saphire or helium or hydrogen or oxygen)	USPAT	OR	ON	2005/04/23 13:54
L14	336	438/311	USPAT	OR	ON	2005/04/23 13:50
L15	160	438/475	USPAT	OR	ON	2005/04/23 13:50
L16	978	438/738	USPAT	OR	ON	2005/04/23 13:50
L17	111	438/752	USPAT	OR	ON	2005/04/23 13:51
L18	540	438/753	USPAT	OR	ON	2005/04/23 13:51
L19	628	438/756	USPAT	OR	ON	2005/04/23 13:51
L20	338	438/757	USPAT	OR	ON	2005/04/23 13:51
L21	1879	438/706	USPAT	OR	ON	2005/04/23 13:51
L22	1478	438/745	USPAT	OR	ON	2005/04/23 13:52
L23	1	("6335292").PN.	USPAT	OR	OFF	2005/04/23 13:53
L24	1	("6171923").PN.	USPAT	OR	OFF	2005/04/23 13:53
L25	1	("5976945").PN.	USPAT	OR	OFF	2005/04/23 13:53
L26	. 1	25 and (cylindrial or cavity or polygonal or concave or convex or sub or surface or removal or etch or etching or insulating or entire or atom or atoms or implantation or implanting or zone or wet or dry or silico or oxide or nitride or diamond or hafnium or lanthanum or aluminum or zirconium or saphire or helium or hydrogen or oxygen)	USPAT	OR	ON	2005/04/23 13:55
L27	1	("5780885").PN.	USPAT	OR	OFF	2005/04/23 13:55
L28	1	("5576250").PN.	USPAT	OR	OFF	2005/04/23 13:55
L29	1	("4956314").PN.	USPAT	OR	OFF	2005/04/23 13:55

L30 1 29 and (cylindrial or cavity or polygonal or concave or convex or sub or surface or removal or etch or etching or insulating or entire or atom or atoms or implantation or implanting or zone or wet or dry or silico or oxide or nitride or diamond or hafnium or lanthanum or aluminum or zirconium or saphire or helium or hydrogen or oxygen)		OR	ON	2005/04/23 13:55
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